



High temperature ferromagnetism in cubic Mn-doped ZrO₂ thin films

Nguyen Hoa Hong^{a,*}, Chul-Kwon Park^a, A.T. Raghavender^a, Antoine Ruyter^b, Ekaterina Chikoidze^c, Yves Dumont^c

^a Nanomagnetism Laboratory, Department of Physics and Astronomy, Seoul National University, Seoul 151-747, South Korea

^b Laboratoire GREMAN, UMR 7347 CNRS - Université F. Rabelais, Parc de Grandmont, 37200 Tours, France

^c Laboratoire GEMaC, UMR 8635 Université de Versailles St Quentin en Yvelines - CNRS, 45, Av. des Etats-Unis, 78035 Versailles Cedex, France

ARTICLE INFO

Article history:

Received 13 February 2012

Received in revised form

20 April 2012

Available online 15 May 2012

Keywords:

Mn-doped ZrO₂

Ferromagnetic semiconductor/insulator

Spintronic

Thin film

ABSTRACT

Theory has predicted that high temperature ferromagnetism (FM) should be found in cubic fakediamonds, Mn-doped ZrO₂. Experimentally, it is shown that Mn-doped ZrO₂ ceramics are not ferromagnetic, but the nanosized Mn-doped ZrO₂ thin films grown on LaAlO₃ substrates can be ferromagnets with T_C above 400 K. The largest saturated magnetic moment (M_s) is huge as of about 230 emu/cm³ for the Mn_{0.05}Zr_{0.95}O₂ films, and it decreases as the Mn content increases. The intrinsic FM is strongly associated with the cubic structure of Mn-doped ZrO₂, and the Mn–Mn interactions via oxygen intermediates are important. No electrical conductivity is observed. Mn-doped ZrO₂ thin films can be truly considered as excellent candidates for spintronic applications.

© 2012 Elsevier B.V. All rights reserved.

1. Introduction

Materials that can be used for spintronics must have both charge and spin that can be manipulated at room temperature. Thus, many research groups have tried to modify semiconductors in order to make them simultaneously room temperature ferromagnetic. After the theoretical suggestion of Dietl in 2000 [1] for doping Mn into ZnO in order to create magnetic *p*-type semiconductors with magnetic interaction via dopants, many experimentalists have investigated various oxides such as ZnO, TiO₂, SnO₂ and HfO₂ [2]. Even though they can be made ferromagnetic, the mechanism seems to be very different from what was expected: in most of the cases, it is proved that transition-metal doping does not play any key role, and the defects/oxygen vacancies should be the source for magnetism [3–8]. But the problem is, if the observed ferromagnetism (FM) is due to defects, then it is very difficult to control and manipulate for the purpose of applications. Therefore, we still look for a more certain and stable candidate.

Since the requirement for a good spintronics material is a big difference between the majority and minority spin density of states at the Fermi level, Ostanin et al., based on their *ab initio* electronic structure calculations, have suggested that Mn-doped cubic zirconia, which is known as synthetic diamond, might be a promising candidate for spintronics [9]. They predicted that Mn-doped ZrO₂ ceramics could be ferromagnetic above 500 K.

This material is half-metallic with the majority and minority spin Mn impurity states lying in the wide gap of zirconia. The Mn concentration can exceed 40 at%, and the high- T_C FM is robust to oxygen vacancy defects, and thus facilitates the Mn impurities to distribute on the Zr *fcc* sublattice [9]. Theoretically, Mn-stabilized ZrO₂ is considered as a promising future spintronic material. Since 2007, some groups have tried, but not achieved: results of non-ferromagnetic phase in Mn-doped ZrO₂ were reported [10,11]. In some other cases, ferromagnetic phase was found, but the observed FM was supposed to be due to defects, since the pristine ZrO₂ films were found also ferromagnetic [12]. It seems that Mn doping does not play any big role in such a case. From that report, it looks like ZrO₂ should be classified as all other oxides (TiO₂, ZnO, SnO₂, and HfO₂) where one can manipulate its FM by controlling defects and oxygen vacancies. If it is really the case, then again, Mn-doped ZrO₂ should not be an ideal candidate for spintronics as it is hoped. However, nothing is very certain about this yet.

Our aim is to realize the intrinsic room temperature ferromagnetic Mn-doped ZrO₂ in order to verify if they can be indeed useful for the device market. In this paper, we will report about our systematic investigations.

2. Experiment

Mn_xZr_{1-x}O₂ targets (where $x = 0, 0.05, 0.1, \text{ and } 0.3$) were prepared by a sol-gel method. 12- and 80 nm-thick-Mn-doped ZrO₂ films were deposited by the pulsed laser deposition (PLD) technique (248 nm KrF excimer laser, repetition rate of 10 Hz) on

* Corresponding author. Tel.: +82 28806606; fax: +82 28843002.
E-mail address: nguyenhong@snu.ac.kr (N.H. Hong).

(001) LaAlO₃ (LAO) substrates. The partial oxygen pressure (P_{O_2}) was 10^{-4} Torr, and the energy density was 2 J/cm^2 . The substrate temperature was kept at 600°C . After deposition, all films were annealed at 450°C with the same P_{O_2} for 30 min, and then cooled down slowly to room temperature under a P_{O_2} of 20 mTorr. All films were deposited on substrates with the same size ($3.5 \text{ mm} \times 3.5 \text{ mm}$ or $5 \text{ mm} \times 5 \text{ mm}$, depending on each purpose) to be able to compare quantitative values directly. The structural analysis was done by X-ray diffraction (XRD) with Cu K α radiation. The magnetic measurements were performed by a Vibrating Sample Magnetometry (VSM) in Quantum Design Inc. PPMS under a magnetic field from 0 to 2 T in the range of temperature from 380 K down to 5 K and a magnetic force microscope (MFM-Solver LS (NT-MDT)) operated at room temperature in zero field). For VSM measurements, magnetic moment of films and bare LaAlO₃ substrates of exactly the same dimensions were measured at the same conditions, in order to get rid of systematic error while subtracting.

3. Results and discussions

XRD data of Mn-doped ZrO₂ films are shown in Fig. 1. One can see that 5% Mn-doped ZrO₂ film has the best XRD pattern with c-axis orientation and shows clearly the ZrO₂ cubic structure, while the crystallinity becomes worse when the Mn concentration surpasses 10%.

Fig. 2 shows magnetization as a function of magnetic field applied parallel to the film plane at room temperature for all 80-nm-thick films with different concentrations of Mn. One can see that, except the undoped ZrO₂ film that is paramagnetic, all other films are ferromagnetic. The largest magnetic moment, and actually very huge, is obtained in the film with a very modest Mn

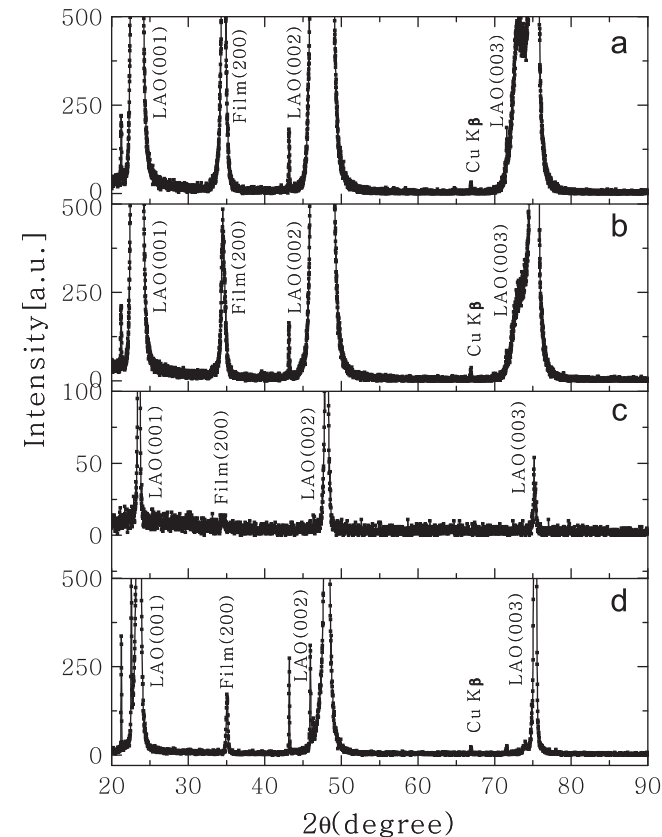


Fig. 1. XRD patterns of (a) ZrO₂, (b) 5% Mn-doped ZrO₂, (c) 10% Mn-doped ZrO₂, and (d) 30% Mn-doped ZrO₂ thin films (with the same thickness of 80 nm).

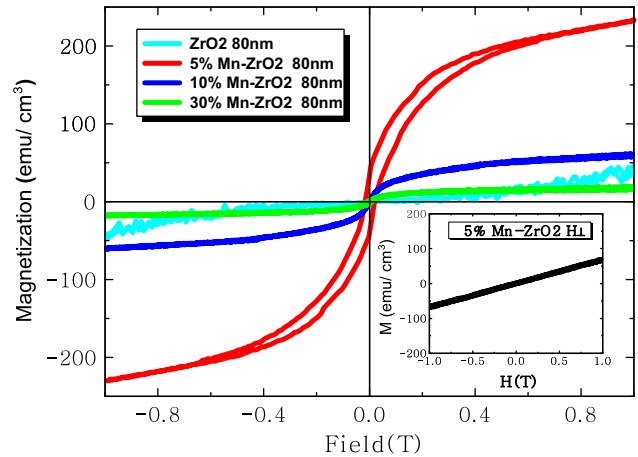


Fig. 2. Magnetization versus magnetic field (applied parallel to the film plane) taken at 300 K for 80-nm-thick Mn_xZr_{1-x}O₂ films (where $x = 0; 0.05, 0.1$ and 0.3). The inset shows $M-H$ curve measured in magnetic field perpendicular to the film plane for the 5% Mn-doped ZrO₂ film taken at 300 K.

concentration of 5% (saturated magnetization, $M_s = 230 \text{ emu/cm}^3$). As the Mn concentration increases, the magnetic moment enormously decreases. When Mn content reaches 30%, it loses 1 order of magnitude. From the inset for $M-H$ curve (taken at 300 K) with magnetic field applied perpendicular to the film plane for the 5% Mn-doped ZrO₂ film, it is seen that at room temperature, in that configuration, the film shows a linear behavior without any saturation even up to 9 T (not shown in figure). It means that there is a strong anisotropy in the film (in-plane should be easy-axis). This observation is quite surprising since ZrO₂ crystal structure is cubic, but manganese valence states are 4^+ or 3^+ substituted in zirconium site that should have a non-zero orbital moment. However, it can be understood in terms of the texture of the film growth.

Ostanin et al. [9] predicted that Mn concentration can exceed 40%, and even the Curie temperature (T_C) will increase and become much higher. But experimentally, it is proved not to be true. Seeing the degradation of magnetization as Mn concentration increases, it is not possible to think that T_C can be improved in such a case. More likely, once Mn is heavily doped, it cannot be incorporated well in the lattice, and its cubic structure is distorted. Look back at the XRD data for films (Fig. 1) that at a high concentration of Mn, the peak of ZrO₂ phase is very weak and vague, implying an amorphous structure, in the contrary with the case of slightly doped as Mn = 5%, film is very well oriented, showing clearly ZrO₂ phase with cubic structure ($a = 5.101 \text{ \AA}$ for the undoped ZrO₂ case, and reduced when Mn concentration increases, $a = 5.09 \text{ \AA}$ for Mn of 5%).

In contrast to the result reported in Ref. [12] that their undoped ZrO₂ films would be ferromagnetic, our result firmly shows that if the phase is well cubic, our laser ablated undoped ZrO₂ film is paramagnetic. One cannot blame that FM in Mn-doped ZrO₂ is due to oxygen vacancies/defects, since it shows clearly that the FM can be obtained only after doping Mn to the ZrO₂ host. The ZrO₂ is known to be wide band gap semiconductor ($E_g \sim 5-7 \text{ eV}$). Our films of Mn-doped ZrO₂ are very electrically resistive, with almost no free carriers at room temperature. If we try to attribute the observed FM to Mn doping, so that express magnetization per Mn atom, it will lead to the value of M_s as $13.8 \mu_B/\text{Mn}$. To have the magnetization of the sample in unit of Bohr magnetons per Mn, one must normalize based on the number of Mn cations thought to be in the sample. Note that this value of magnetization in Bohr magnetons per Mn is useful only for reference because it may mislead when the oxides are not dilute magnetic

Download English Version:

<https://daneshyari.com/en/article/10709495>

Download Persian Version:

<https://daneshyari.com/article/10709495>

[Daneshyari.com](https://daneshyari.com)